## 《基于微纳光纤双模式干涉的亚波长聚焦光场及光捕获应用》

## 的补充材料

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图 S1 模式组 HE<sub>11</sub> + EH<sub>11</sub>的聚焦光场捕获不同直径的纳米颗粒时的捕获刚度. 插图为聚焦 光场在焦平面上的电场分布|*E*|,黑色方点为焦点  $h_1$  (在 *xy* 平面上位于(*x*, *y*) = (0.5, 0) µm) 的捕获效果;红色圆点为焦点  $h_2$  (在 *xy* 平面上位于(*x*, *y*) = (0, 0.44) µm) 的捕获效果 Fig. S1. Trapping stiffness for 85 nm polystyrene (PS) nanoparticles versus diameters under the two-mode interference of *x*-HE<sub>11</sub> and even-EH<sub>11</sub>. Considering a nanoparticle located at a position of (*x*, *y*) = (0.5, 0) µm (black dots) and (*x*, *y*) = (0, 0.44) µm (red dots) respectively, longitudinal forces could be calculated by moving nanoparticles along the *z*-direction. Thus, one obtained  $\kappa_{trap}$ via the slopes of longitudinal forces near the trapping equilibrium position. The inset shows the *E*field in the focal plane, where two kinds of foci were referred to as  $h_1$  and  $h_2$ .



图 S2 准 x 线偏振态模式组 HE<sub>11</sub> 和 HE<sub>12</sub> 的聚焦光场对 PS 颗粒的纵向捕获强度 (黑色曲线 为纵向光力; 红色曲线为势能. 插图为计算模型)

Fig. S2. Longitudinal trapping strength for an 85 nm PS particle under two-mode interference of *x*-polarized  $HE_{11}$  and  $HE_{12}$  (Longitudinal force (black curve) and potential energy (red curve) along the fiber axis. The inset shows the calculated model).



图 S3 模式组 HE<sub>11</sub>+HE<sub>12</sub>的聚焦光场及对直径 85 nm 的 PS 颗粒的捕获强度 (a) *xz* 平面; (b) *yz* 平面; (c) 焦平面上的电场强度的模值分布(|*E*|),单位为 V/m. (d) 捕获平面上的势能密度分布(三维图)和横向光力分布(底部的二维图),其中势能单位为 *k*<sub>B</sub>T/W、光力单位为 pN/W. 图(c), (d)中比例尺为 0.5 μm

Fig. S3. *E*-field and trapping strength for an 85 nm PS particle under two-mode interference of even-HE<sub>11</sub> and *x*-HE<sub>12</sub>. *E*-fields in (a), (b) the central cross-sections (*xz* and *yz* planes) and (c) the focal plane (*xy* plane at  $z = 0.25 \mu$ m) have a unit of V/m. Solid rectangles depict microfiber profiles. (d) Potential energy densities (3D profile) in trapping planes, with a unit of *k*<sub>B</sub>T/W. The image below shows the transverse force exerted on the nanoparticle in the trapping plane: the color scale indicates the magnitude of the force and the arrows indicate its direction. The scale bars in panels (c) and (d) are 0.5 µm.



图 S4 模式组 HE<sub>11</sub>+EH<sub>11</sub>在不同相对功率比下的归一化电场强度, HE<sub>11</sub>模式的功率保持 1.04419 fW (a)  $P_{\text{HE}}$ :  $P_{\text{EH}} = 1$ : 5.28; (b)  $P_{\text{HE}}$ :  $P_{\text{EH}} = 1$ : 11.88; (c)  $P_{\text{HE}}$ :  $P_{\text{EH}} = 3$ : 1 Fig. S4. Normalized *E*-field of interference pattern via the two-mode set of *x*-HE<sub>11</sub> and even-EH<sub>11</sub> with diverse power ratios, one kept the power of *x*-HE<sub>11</sub> mode to be 1.04419 fW: (a)  $P_{\text{HE}}$ :  $P_{\text{EH}} = 1$ : 5.28; (b)  $P_{\text{HE}}$ :  $P_{\text{EH}} = 1$ : 11.88; (c)  $P_{\text{HE}} : P_{\text{EH}} = 3$ : 1.



图 S5 模式组 HE<sub>11</sub>+EH<sub>11</sub>的聚焦光场捕获直径 85 nm 的 PS 颗粒时的横向效果(黑色曲线为 纵向光力;红色曲线为势能;插图为计算模型) (a),(b) 线偏振态模式组;(c),(d) 圆偏振态 模式组。

Fig. S5. Transverse trapping strength for an 85 nm PS particle under the two-mode interference of x-HE<sub>11</sub> and even-EH<sub>11</sub> (Transverse force (black curves) and potentials (red curves) in trapping planes under (a), (b) linear and (c), (d) circular polarization excitation. The insets show the calculated models).